BY APPLICANT (Use several sheets if necessary)			Akihiko	Akihiko ENDO et al.				
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	OTHER DOCUMEN	TS (Including Au	thor Title Date Per	tinent Pages Et	2)			
1	Fumio SHIMURA, "Semica York, Berkeley, Boston, Lo	onductor and Si	licon Crystal Tech	nology", Acade	mic Press, Inc.,	San Diego	, New	
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1	Fumio SHIMURA, "Semiconductor and Silicon Crystal Technology", Academic Press, Inc., San Diego, New York, Berkeley, Boston, London, Sydney, Tokyo, Toronto, 1989, pp. ii-viii, 1, 232-233, and 274-275

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\*EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.